

In situ analysis of the nucleation of O- and Zn-polar ZnO nanowires using synchrotron-based X-ray diffraction

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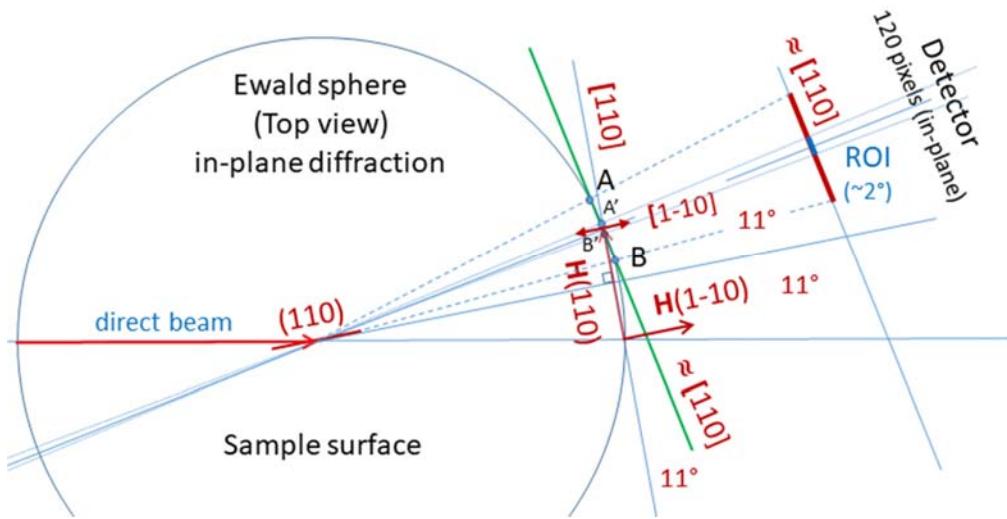


Fig. S1 Schematic representing the configuration used during the in-plane XRD measurements.

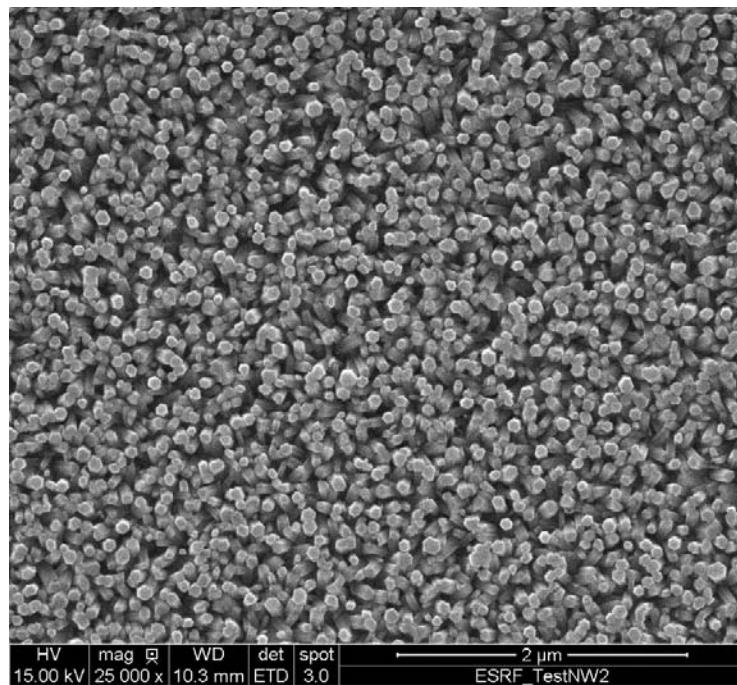


Fig. S2 Typical FESEM image of ZnO NWs grown on a *c*-axis oriented polycrystalline ZnO seed layer using the designed leak-tight growth cell.